



# **Vapor Pressure of Antimony Triiodide**

by Patrick J Taylor, Ryan Enck, Charles Rong, and Jay R Maddux

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# **Contents**

List	ist of Figures	
1.	Introduction	1
2.	Vapor Pressure	1
3.	Experiment	3
4.	Discussion and Measurements	5
5.	Significance	6
6.	MBE Doping Strategy	7
7.	Conclusions	7
8.	References	8
List	of Symbols, Abbreviations, and Acronyms	9
Dist	tribution List	10

# **List of Figures**

Fig. 1	(left) Knudsen cell showing the orifice and (right) the ampoule of high-purity SbI <sub>3</sub>	. 3
Fig. 2	Equilibrium vapor pressure of SbI <sub>3</sub> as a function of inverse temperature	. 4
Fig. 3	Effective $\Delta H_{\text{vapor}}$ of SbI <sub>3</sub> as a function of temperature	. 6

#### 1. Introduction

Antimony triiodide (SbI<sub>3</sub>) is one of the most effective n-type dopants for (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> thermoelectric materials. <sup>1,2</sup> Precise control of the concentration of the SbI<sub>3</sub> dopant in (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> is the key to obtaining good n-type materials, and consequently, the highest-performance thermoelectric devices. There is an ideal amount of SbI<sub>3</sub> that yields an optimum concentration range of 3 to 5×10<sup>19</sup>/cm<sup>3</sup> of n-type carriers. <sup>2</sup> All commercial bulk thermoelectric devices have doped n-type materials prepared to achieve this n-type dopant concentration range.

To effect n-type doping in bulk materials, an appropriate amount of SbI<sub>3</sub> is added to (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> source materials, which are all co-melted at temperatures greater than 600 °C. In the melt, SbI<sub>3</sub> chemically decomposes and liberates free antimony (Sb) and iodine (I) atoms, which become substitutionally incorporated onto the (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> crystal lattice during subsequent solidification and Bridgman crystal growth. Substitutional Sb is isoelectronic on a bismuth (Bi) site and has little consequence on doping. However, substitutional I on a tellurium (Te) site will serve as a singly ionized donor, and in the case of I on a Bi or Sb site, will act as a doubly ionized donor. In either of those cases, substitutional I causes n-type conduction.

The growth of epitaxial single-crystal *thin films* of n-type (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> materials presents new doping challenges because it is a nonequilibrium process. (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> epitaxial materials have been grown by molecular beam epitaxy (MBE)<sup>3</sup> and organometallic vapor phase epitaxy (OMVPE) growth techniques.<sup>4</sup> However, the use of this preferred SbI<sub>3</sub> dopant in either MBE or OMVPE is not reported. MBE and OMVPE are distinct from the bulk technique because crystal growth proceeds by the vapor phase and at a significantly lower temperature, approximately 300 °C. Because the material never melts, the incorporation of SbI<sub>3</sub> into epitaxial films would necessarily proceed by some alternate vapor phase mechanism. The goal of the present work, therefore, is to understand the vapor pressure behavior of SbI<sub>3</sub> as a stepping-stone toward the overall goal of employing SbI<sub>3</sub> during MBE growth to obtain extrinsically doped n-type (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> epitaxial materials.

#### 2. Vapor Pressure

In a classical MBE growth process, each individual source material is heated to some temperature (T) to produce an equilibrium vapor having pressure (P) that can be made to condense on a crystalline substrate and epitaxially grow single crystals of the desired chemistry. The production of an equilibrium vapor pressure above Approved for public release; distribution is unlimited.

each condensed material is a phase transformation process where there is a net change in molar-specific volume ( $\Delta V$ ) from the condensed phase to its vapor. The rate of that phase change depends on the enthalpy of vaporization ( $\Delta H_{vapor}$ ) and is governed by thermodynamics. The Clausius-Clapeyron relationship shown in Eq. 1 describes the thermodynamics that governs the phase transformation between phases:

$$\frac{\mathrm{dP}}{\mathrm{dT}} = \frac{\left(\Delta H_{\mathrm{vapor}}\right)}{\Delta V} \begin{bmatrix} 1\\ T \end{bmatrix}. \tag{1}$$

For a phase transformation from a condensed phase to a vapor phase, one may assume the relative change in molar-specific volume ( $\Delta V$ ) is essentially equal to the specific volume of the vapor ( $V_{vapor}$ ) because vapor phases usually occupy significantly larger volumes than those occupied by condensed phases ( $V_{condensed}$ ).

$$\Delta V = (V_{\text{vapor}} - V_{\text{condensed}}) \approx V_{\text{vapor}}. \tag{2}$$

If one assumes the obtained vapor behaves according to the ideal gas law, then  $V_{vapor} = RT/P$ , where R is the common gas constant (8.314 J/mol-K), and Eq. 1 may be rewritten as

$$\frac{dP}{dT} = \frac{P(\Delta H_{\text{vapor}})}{RT^2}.$$
 (3)

Rearranging Eq. 3 and integrating between 2 thermodynamic states, say state "1" and state "2", as per Eq. 4,

$$\int_{P1}^{P2} \frac{\mathrm{dP}}{P} = \frac{\left(\Delta H_{\text{vapor}}\right)}{R} \int_{T1}^{T2} \frac{dT}{T^2} \tag{4}$$

yields the analytical, closed-form Clausius-Clapeyron equation for equilibrium vapor pressure as a function of T evaluated between states 1 and 2:

$$\ln(P) = \frac{(\Delta H_{\text{vapor}})}{RT} \text{ or } P = \exp\left[\frac{(\Delta H_{\text{vapor}})}{RT}\right] + C.$$
 (5)

Equation 5 predicts an exponential dependence of equilibrium vapor pressure on inverse-temperature with the slope of  $(\Delta H_{vapor}/R)$ . One method of experimentally determining  $\Delta H_{vapor}$ , therefore, is to measure the equilibrium vapor pressure of any material as a function of inverse-temperature where the slope of the data can be used to directly determine  $\Delta H_{vapor}$ .

# 3. Experiment

An ampoule of 99.999% pure SbI<sub>3</sub> was loaded into a Knudsen cell fabricated from pyrolytic boron nitride (p-BN). p-BN is chemically nonreactive and inert over the entire temperature range of concern, so there are no chemical effects other than the phase change of SbI<sub>3</sub> within. Care was taken to minimize exposure of SbI<sub>3</sub> to lab air because it is hygroscopic and loses its brilliant orange color (Fig. 1, right) as it adsorbs water from the lab air.

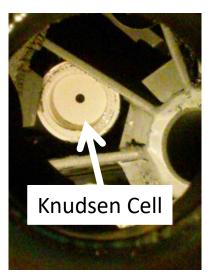




Fig. 1 (left) Knudsen cell showing the orifice and (right) the ampoule of high-purity SbI<sub>3</sub>

A Knudsen cell is a special, almost fully enclosed chamber that has a small orifice on one end. A material placed inside the Knudsen cell is heated and will respond by generating an equilibrium vapor pressure inside according to the Clausius-Clapeyron equation. Because some vapor can escape from the small orifice, the equilibrium vapor pressure can be determined by techniques that can quantify the efflux of vapor. Further, the enthalpy of vaporization,  $\Delta H_{vapor}$ , can be determined by measuring the temperature dependence of that pressure.

The Knudsen cell assembly was mounted onto an MBE system that can achieve vacuum on the order of  $10^{-10}$  Torr. Because of that extremely strong vacuum, vapor pressure measurements can be expanded by more than 10 orders of magnitude compared to previous work. The equilibrium vapor pressure within the MBE is measured by the use of a common hot-cathode Bayard–Alpert gauge.

For the present study, the range of temperatures where the vapor pressure is small was investigated and compared to previously published data from the temperature range where the vapor pressure is relatively high. Three independent measurements of the vapor pressure were conducted in this study and are color-coded red, blue,

and purple in Fig. 2. For each measurement, the temperature of the Knudsen cell was very slowly increased starting from 14  $^{\circ}$ C and allowing sufficient time for the SbI<sub>3</sub> within the Knudsen cell to reach thermal equilibrium.

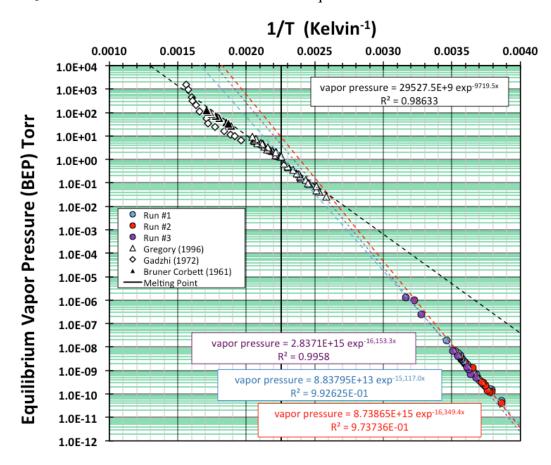


Fig. 2 Equilibrium vapor pressure of SbI<sub>3</sub> as a function of inverse temperature

For the analysis, the pressure was determined as the average of the 3 separate data collections ranging from below room temperature, -14 °C, to slightly above room temperature, 43 °C. As shown in Fig. 2, the obtained data were self-consistent with little divergence. In this temperature range, the slope of the averaged pressure data from 3 collections is  $(\Delta H_{vapor}/R)$  and follows the exponential of (-15,452.91/T) and yields  $\Delta H_{vapor} = -128.48$  kJ/mol.

Further, the extrapolation to higher-temperature data show reasonable consistency with previously published data; the data would connect to form a piecewise continuous curve. There is some nonlinearity and softening in the global slope as the melting point is approached, and then surpassed. On Fig. 2, the previously published data suggest a softer ( $\Delta H_{vapor}/R$ ) slope, which is found to be (-9719.5/T), and that suggests a softening of the enthalpy of vaporization to

 $\Delta H_{vapor} = 80.81$  kJ/mol. In the mid-temperature range, as the melting point is approached, the ( $\Delta H_{vapor}/R$ ) slope moderates to an intermediate value of  $\Delta H_{vapor} = 87.6$  kJ/mol. This progressive reduction is most likely associated with increased translational, rotational, and vibrational entropies and larger-amplitude intermolecular oscillation as the solid approaches the melting point.

The melting point of  $SbI_3$  is 170.6 °C and is indicated on Fig. 2 by the vertical black line intersecting the x-axis at approximately 1/T = 0.00225/K. Above the melting point, there are more divergent data sets from previously published work that imply the thermal decomposition of  $SbI_3$  into unknown subspecies, which are not relevant to the present work.

#### 4. Discussion and Measurements

Bruner and Corbett<sup>5</sup> published results from their study of the vapor pressure of SbI<sub>3</sub> at very high temperatures as a step toward understanding the high-temperature behavior of new linear-molecule structural forms of halide given by the reaction  $4\text{SbI}_3 + 2\text{Sb} = 3\text{Sb}_2\text{I}_4$ . For pure liquid SbI<sub>3</sub>, however, they reported a similar nonlinearity (softening) in the pressure data as temperature is increased, and at high temperature in the range of 260 °C and extending to 405 °C. They reported that their analysis of the pressure data for SbI<sub>3</sub> yielded  $\Delta H_{\text{vapor}} = -64 \text{ kJ/mol}$  near the boiling point of 401.6 °C.

Gadzhi and coworkers<sup>6</sup> measured the vapor pressure at a similar but hotter range than that investigated by Bruner and Corbett. Because their data include the highest temperatures ever recorded, there is likely some chemical decomposition of SbI<sub>3</sub> (cracking) into distinct species such as free I and SbI<sub>(3-x)</sub> with a concomitant supra nonlinear increase in the vapor pressure at the highest temperatures.

Ferro and colleagues<sup>7</sup> studied vapor pressure as a step toward understanding vapor transport of chemical species. In contrast to the earlier work of Bruner and Corbett, Ferro and colleagues' work focused on colder SbI<sub>3</sub> solid near the melting point, and thus a much lower-temperature range: starting at 109 °C and extending to 277 °C. Using 2 different techniques to determine the equilibrium vapor pressure, they reported very linear behavior and  $\Delta H_{\text{Vapor}} = -109.3 \text{ kJ/mol}$ .

The work of Gregory<sup>8</sup> did not focus on the determination of  $\Delta H_{vapor}$ , but instead attempted to reconcile some of the apparent inconsistencies in vapor pressure across the entire temperature range of past work. Gregory used absorbance by the vapor phase as an index of vapor pressure. One finding Gregory validated was that the thermodynamic behavior of SbI<sub>3</sub> follows the trend of progressively reducing

 $\Delta H_{vapor}$  as temperature increases. The measurements of Gregory were generally consistent with past work, and that suggests the nonlinear, softening  $\Delta H_{vapor}$  with temperature of previous reports is generally consistent.

# 5. Significance

This work expands the breadth of vapor pressure measurement from the previous 6 orders of magnitude to 16 orders of magnitude, and represents a more comprehensive perspective of the equilibrium vapor pressure of this interesting and technologically important material. The present work is consistent with previous determinations of  $\Delta H_{vapor}$  on the order of approximately 100 kJ/mol (Fig. 3). The broadly arcing curve suggests that the  $\Delta H_{vapor}$  value one obtains is, in part, determined by the temperature where the data were measured:  $\Delta H_{vapor}$  will be higher at lower temperature and lower at higher temperature. Ignoring entropy contributions to sublimation allows the contributions to the sublimation to be one lumped term called the effective enthalpy of sublimation. In that case, the effective  $\Delta H_{vapor}$  of SbI<sub>3</sub> has a strong, nonlinear temperature dependence.

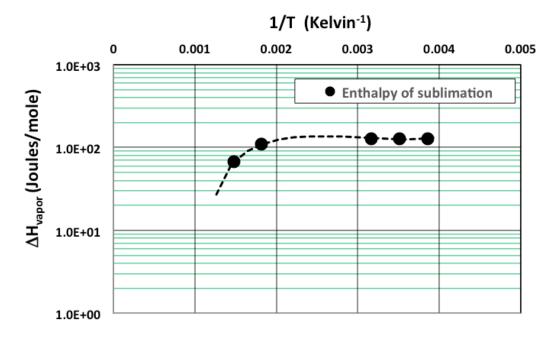


Fig. 3 Effective ΔHyapor of SbI<sub>3</sub> as a function of temperature

# 6. MBE Doping Strategy

To be effective as a dopant, I must be incorporated within the (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> crystal lattice during growth. If one assumes unity incorporation (i.e., one I becomes incorporated from one SbI<sub>3</sub> molecule that hits the surface), then a simple ratio of pressures could yield an estimate of the obtained doping concentration. During (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> MBE growth, the growth rate is governed by the pressure of Bi metal. As a consequence of that, the ratio of SbI<sub>3</sub> pressure to Bi pressure can therefore be an approximate index for the expected doping concentration.

If, say, the overall concentration of desired doping for I atoms is approximately  $5\times10^{19}$  I atoms per cm<sup>3</sup> and assuming each I donates one extra electron, then that would yield an n-type carrier density of  $5\times10^{19}$ /cm<sup>3</sup>. If the (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> matrix concentration is roughly  $5\times10^{23}$  atoms per cm<sup>3</sup>, then the preferred ratio of Bi pressure to SbI<sub>3</sub> pressure would be 10,000:1. For a common Bi pressure during (Bi,Sb)<sub>2</sub>(Te,Se)<sub>3</sub> MBE growth, a Bi pressure of  $5\times10^{-7}$  Torr is not unreasonable. In the case where Bi pressure is  $5\times10^{-7}$  Torr, one would target an SbI<sub>3</sub> pressure of  $5\times10^{-11}$  Torr; refer to Fig. 2. One would, therefore, select an SbI<sub>3</sub> temperature of roughly -10 °C to achieve an SbI<sub>3</sub> pressure of  $5\times10^{-11}$  Torr, resulting in a doping concentration of  $5\times10^{19}$ /cm<sup>3</sup>.

#### 7. Conclusions

The equilibrium vapor pressure of SbI<sub>3</sub> has been measured over a temperature range from 253 to 320 K (–20 to 47 °C) using a classical Knudsen cell method. An analysis of the slope of that data as a function of temperature is one measure of the enthalpy of sublimation ( $\Delta H_{vapor}$ ), and a value of  $\Delta H_{vapor} = -128.48$  kJ/mol has been obtained for SbI<sub>3</sub>.

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# List of Symbols, Abbreviations, and Acronyms

Bi bismuth

I iodine

MBE molecular beam epitaxy

OMVPE organometallic vapor phase epitaxy

P pressure

p-BN pyrolytic boron nitride

Sb antimony

SbI<sub>3</sub> antimony triiodide

Se selenium

T temperature

Te tellurium

 $\Delta H_{vapor}$  enthalpy of vaporization

 $\Delta V$  net change in molar-specific volume

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